





IOI Follow-up Workshop for NPMs "Monitoring of Psychiatric Facilities" 21 – 23 June 2016 | Vilnius, Lithuania

In 2015 the IOI established a new training cooperation with the Association for the Prevention of Torture (APT), which resulted in a first IOI workshop with a substantive focus on the topic of National Preventive Mechanisms under the Optional Protocol to the Convention against Torture and Other Cruel, Inhuman or Degrading Treatment or Punishment (OPCAT).

Due to the great success of this first NPM workshop the IOI decided to offer a follow-up NPM training which is of course again directed specifically towards the staff of Ombudsman institutions acting as National Preventive Mechanism (NPM) in their respective countries.

Building on the feedback from participants of the first training, the focus of this follow-up workshop will lie on the **monitoring of psychiatric facilities**. The training will cover topics such as involuntary hospitalization and treatment or how to evaluate the use of restrictive measures. It will tackle general challenges and ethical concerns that may arise during the monitoring of psychiatric facilities. Provisions are made to ensure a more practical approach for this workshop and our host is therefore planning to arrange a visit at a psychiatric facility. Renowned experts from the APT will lead through the workshop as such. In addition, medical experts will bring their specific expertise in the field of monitoring psychiatric institutions to the table. For more information, please see the tentative program.

This three-day workshop will be hosted by the Seimas Ombudsmen's Office of the Republic of Lithuania and held in **Vilnius** (Lithuania) from **21 – 23 June 2016**. The training will be conducted in English; workshop participants are therefore required to have a high level of English proficiency. To ensure the highest possible training outcome for the participants and to facilitate the organization of the visits to the psychiatric facility, participation is limited to a maximum of 25 people. As a consequence, participation will also be limited to <u>one</u> representative per member institution, in order to allow the attendance of as many member institutions as possible. Feel free however to nominate a second staff member from your office. Should places still be available after the registration deadline, they will be awarded to these second staff members on a first come first served basis.







The workshop as such is offered to IOI member institutions in good standing free of charge. Travel and accommodation costs must be covered by the participants. Hotel options recommended by the workshop host as well as general information (e.g. venue, meals, travel arrangements etc.) can be found in the practical information attached. We recommend booking your room as soon as the IOI General Secretariat has confirmed your participation!

In order to ensure a smooth organisation and efficient planning of the event, the IOI General Secretariat also asks you to register by returning the completed registration form and questionnaire (see attached) to the IOI General Secretariat by Email (<u>ioi@volksanw.gv.at</u>) or fax (+43 1 512 93 88 200) as soon as possible but no later than <u>30 April 2016</u>. Please note that your registration will only be valid if it is accompanied by the completed questionnaire!

The IOI will also be able to provide a small number of scholarships for institutions with limited resources. Scholarships will be awarded by the IOI Executive Committee and include refund for economy airfares and/or accommodation costs. Scholarship applications should be forwarded to the IOI General Secretariat no later than <u>30 April 2016</u>.

The IOI is looking forward to an active participation, a fruitful discussion and exchange of ideas on a subject which is becoming more and more relevant to Ombudsman institutions worldwide. If you have any further questions, please do not hesitate to contact the IOI General Secretariat (ioi@volksanw.gv.at).

forther thank

Günther Kräuter IOI Secretary General